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Role of Cu foil in-situ annealing in controlling the size and thickness of CVD graphene domains

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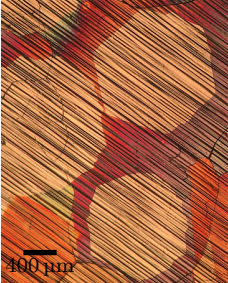
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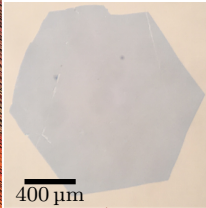
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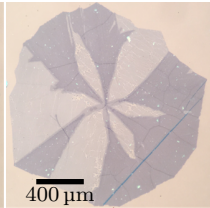
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Single-layer



Multi-layer



Transfer

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